

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:		)	) CONFIRMATION NO.: 3704	
	Kazuhide HASEBE, et al.	)		
U.S. Serial No.: 10/549,851		)	Group Art Unit: 2812	
Filed:	September 23, 2005	)	Examiner: Reema Patel	
For:	METHOD FOR CLEANING FILM-FORMING UNIT			

## RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

A response to the Office Action mailed May 14, 2007 is due by June 14, 2007. The Action required restriction among the following:

Group I of claims 1, 4, 6-11, 12, 15, and 16-20,

Group II of claims 2, 6-11, 13, and 16-20, and

Group III of claims 3, 6-11, 14, and 16-20.

Applicants hereby elect Group I of claims 1, 4, 6-11, 12, 15, and 16-20, drawn to a cleaning method and apparatus which involve a nitrogen-including gas being activated to nitride the surface of a reaction chamber, for examination in this application.

Applicants reserve the right to file divisional application(s) for the non-elected claims in due course.

IFW

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It is submitted that this application now is in condition for examination on the merits and early action in that regard is solicited.

Respectfully submitted,

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